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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/657,606	09/08/2003	David A. Beauchaine	039035/261789	1765	
826 ALSTON & BI	7590 01/18/200 RD LLP	7	EXAM	IINER	
BANK OF AMERICA PLAZA			LEUNG, JENNIFER A		
	RYON STREET, SUIT NC 28280-4000	E 4000	ART UNIT	PAPER NUMBER	
,			1764		
SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE		
3 MO	NTHS	01/18/2007	PAI	PER	

# Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

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	Application No.	Applicant(s)				
•	10/657,606	BEAUCHAINE ET AL.				
Office Action Summary	Examiner	Art Unit				
	Jennifer A. Leung	1764				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPL' WHICHEVER IS LONGER, FROM THE MAILING D.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be timwill apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communicatio D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 10 N	lovember 2006.					
,	2a) This action is <b>FINAL</b> . 2b) ⊠ This action is non-final.					
,	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.				
Disposition of Claims			,			
<ul> <li>4)  Claim(s) 1-25 is/are pending in the application 4a) Of the above claim(s) 1-11 and 20-25 is/are</li> <li>5)  Claim(s) is/are allowed.</li> <li>6)  Claim(s) 12-19 is/are rejected.</li> <li>7)  Claim(s) is/are objected to.</li> <li>8)  Claim(s) 1-25 are subject to restriction and/or</li> </ul>	e withdrawn from consideration.	·				
Application Papers						
9) The specification is objected to by the Examine 10) The drawing(s) filed on <u>08 September 2003</u> is/s  Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Example 11.	are: a)⊠ accepted or b)⊡ objec drawing(s) be held in abeyance. Sec tion is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(	(d).			
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list	es have been received. Es have been received in Application rity documents have been receive (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)	0 T Inter to 2	(DTO 442)				
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO/SB/08)</li> <li>Paper No(s)/Mail Date <u>9-8-03</u>.</li> </ol>	4)  Interview Summary Paper No(s)/Mail Di 5)  Notice of Informal F 6)  Other:	ate				

#### **DETAILED ACTION**

#### Election/Restrictions

1. Applicant's election with traverse of Group II, claims 12-19, in the reply filed on November 10, 2006 is acknowledged. However, because Applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)). Claims 1-11 and 20-25 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim.

### Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 12-19 are rejected under 35 U.S.C. 102(b) as being anticipated by Cecil et al. (US 3,536,522).

Regarding claims 12, 14, 18 and 19, Cecil et al. (see Figure; column 2, lines 31-62; column 3, line 65 to column 4, line 54) discloses an apparatus comprising:

a vessel (i.e., a cylindrical quartz vessel 25) defining an inlet (i.e., at nipple 27) and an outlet (i.e., at nipple 26);

a plurality of pieces of an oxidizable material (i.e., a particulate bed of silicon 24) disposed within the vessel 25, wherein the material is selected so as to oxidize upon exposure to oxygen in the gas such that the gas exiting the vessel through the outlet has less oxygen than the

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gas entering the vessel through the inlet (see column 4, lines 4-11); and

a heater (i.e., electrical resistance coil 31) in thermal communication with the vessel 25 to heat the plurality of pieces of oxidizable material 24.

Regarding claim 13, the apparatus of Cecil et al. meets the claim, because silicon 24 is a material in which a resulting oxide layer is etchable upon exposure to an etchant, as defined by Applicants (for example, see Specification page 4, last paragraph). Please note that the resulting oxide layer and the etchant are not considered part of the apparatus.

Regarding claim 15, the plurality of pieces of oxidizable material **24** are of different sizes (i.e., particles having diameters ranging from ¼" to 100 microns, see column 3, lines 69-72).

Regarding claims 16 and 17, heater 31 is proximate to and at least partially surrounds the vessel 25 (see Figure), and heater 31 is capable of maintaining the material 24 at a temperature between about 600 °C and 1200 °C (see column 3, lines 72-75; column 4, lines 24-34).

Instant claims 12-19 structurally read on the apparatus of Cecil et al.

3. Claims 12-19 are rejected under 35 U.S.C. 102(b) as being anticipated by Smith et al. (US 5,213,767).

Regarding claims 12 and 14, Smith et al. (see FIGs. 1-3; column 3, line 10 to column 4, line 56) discloses an apparatus comprising:

a vessel (i.e., cylinder or column 10) defining an inlet 11 and an outlet 12;

a plurality of pieces of an oxidizable material disposed within the vessel (i.e., a bottom section 16 containing silicon, see column 3, lines 22-48); and

a heater (i.e., an electrically heated furnace 13) in thermal communication with the vessel 10 to heat the plurality of pieces of oxidizable material 16.

Regarding claim 13, the apparatus of Smith et al. meets the claim, because silicon 16 is a material in which a resulting oxide layer is etchable upon exposure to an etchant, as defined by Applicants (for example, see Specification page 4, last paragraph). Please note that the resulting oxide layer and the etchant are not considered part of the apparatus.

Regarding claim 15, the pieces of silicon 16 are of different sizes (column 3, lines 42-51).

Regarding claims 16 and 17, the heater 13 is proximate to and at least partially surrounds the vessel 10 (see figures), and the heater 13 is capable of maintaining the material 16 at a temperature between about 600 °C and 1200 °C (see column 3, lines 52-54).

Regarding claims 18 and 19, the vessel 10 is formed of a material that is non-reactive with the gas, such as quartz (see column 3, lines 54-58).

Instant claims 12-19 structurally read on the apparatus of Smith et al.

### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jennifer A. Leung whose telephone number is (571) 272-1449. The examiner can normally be reached on 9:30 am - 5:30 pm Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Glenn A. Caldarola can be reached on (571) 272-1444. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR

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system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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January 9, 2007